



TEST REPORT

Delivery Date: July 14 2011

1250nm LD Epiwafer

(#0707231-2)

Customer: ECE Department, UCSB

Customer : UCSB

Control No. : 0707231-2

Test data :

1. DXCD

Item	Wafer No.	Spec (Å) ($\pm 10\%$)	test (Å)
1	DLDA1107133- C,D	150	150.49~150.95

2. PL

Item	Wafer No.	Spec(nm)	test (nm)
1	DLDA1107133	1250 \pm 10	1246.6

3. ECV

Item	Run No.	Layer #3(P-InP) (unit: 10^{18} cm^{-3})		Layer #7(N-InP) (unit: 10^{18} cm^{-3})		Layer #10(N-InGaAs) (unit: 10^{18} cm^{-3})	
		Spec.	Test	Spec.($\pm 20\%$)	Test	Spec.($\pm 20\%$)	Test
1	DLDA1107133	2 \rightarrow 1	\sim 1.97	3	\sim 2.86	3	\sim 3.15

Comment :

The super-lattice period had determined by QC200 Diffractometer. The BIO-RAD RPM2000 PL mode is used to measure the wavelength. The concentrations of P-InP & N-InP & N-InGaAs layers are measured by Electro-Chemical C-V Profile.

All wafers are tested under the same criteria. The attached graphs are the prototype of the testing results. All test results are in accordance with customer's specifications.

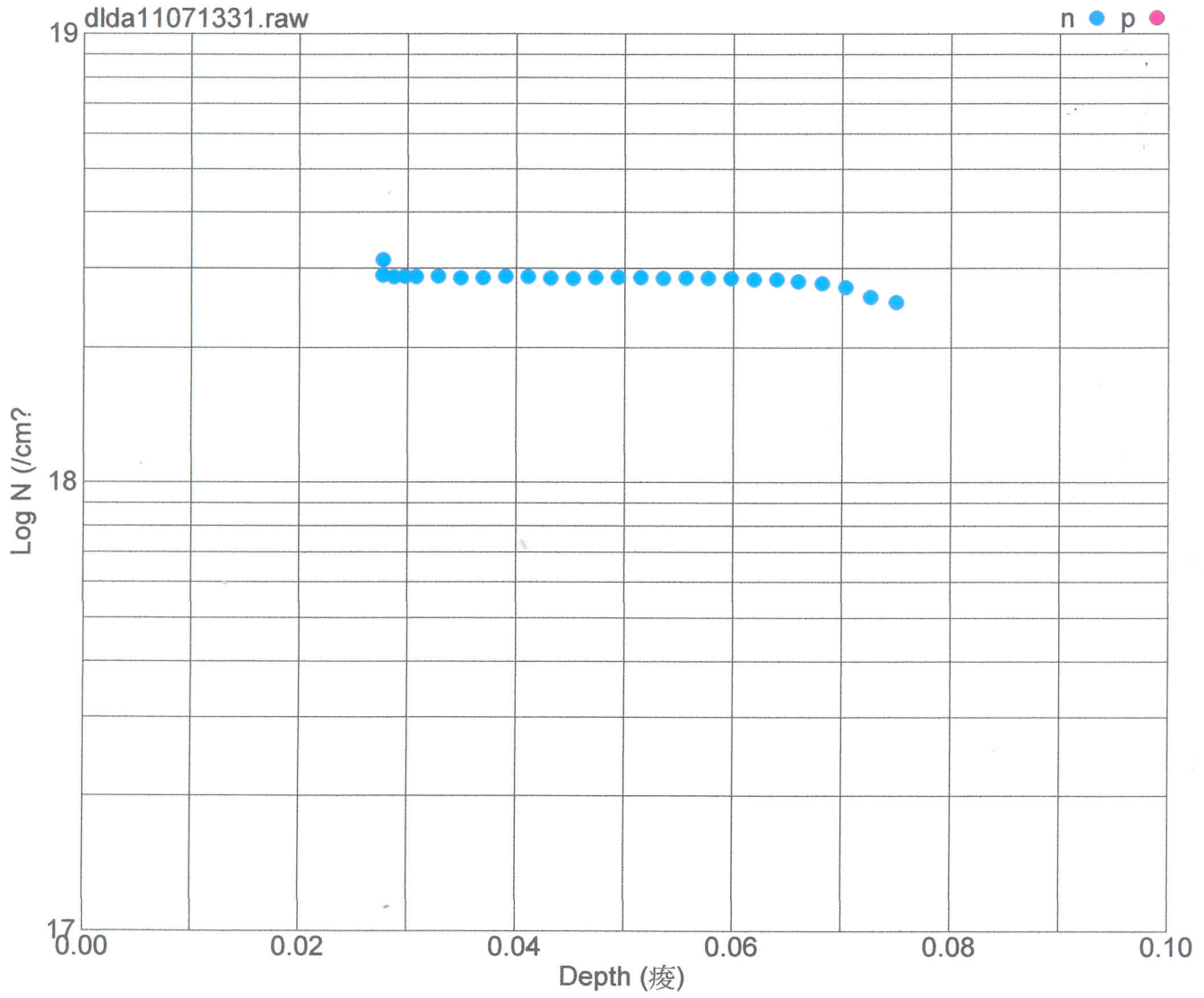
Signature :

Reported By: Jeremy

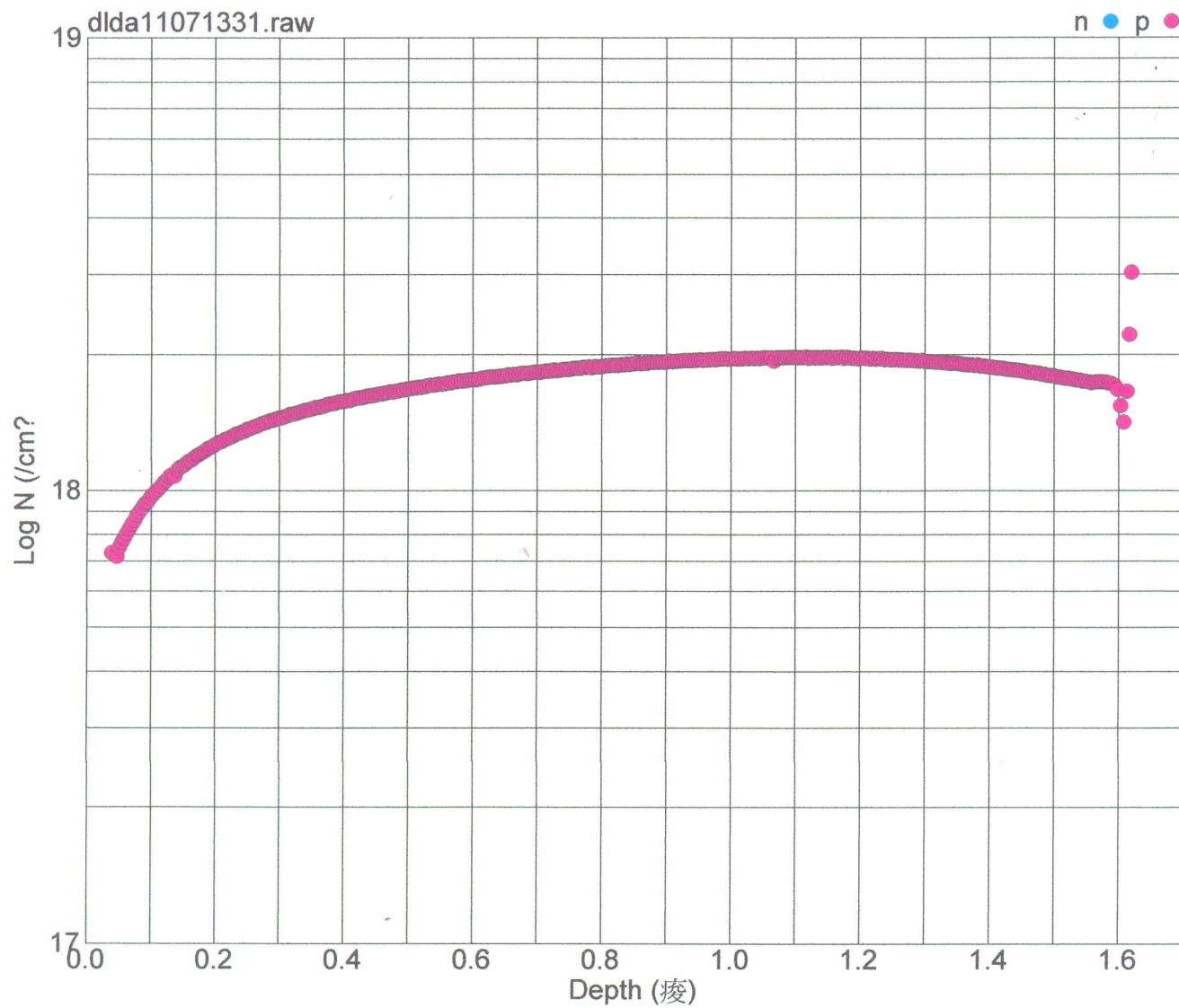
Manager: Brian Wan

Supervisor: Wei Lin

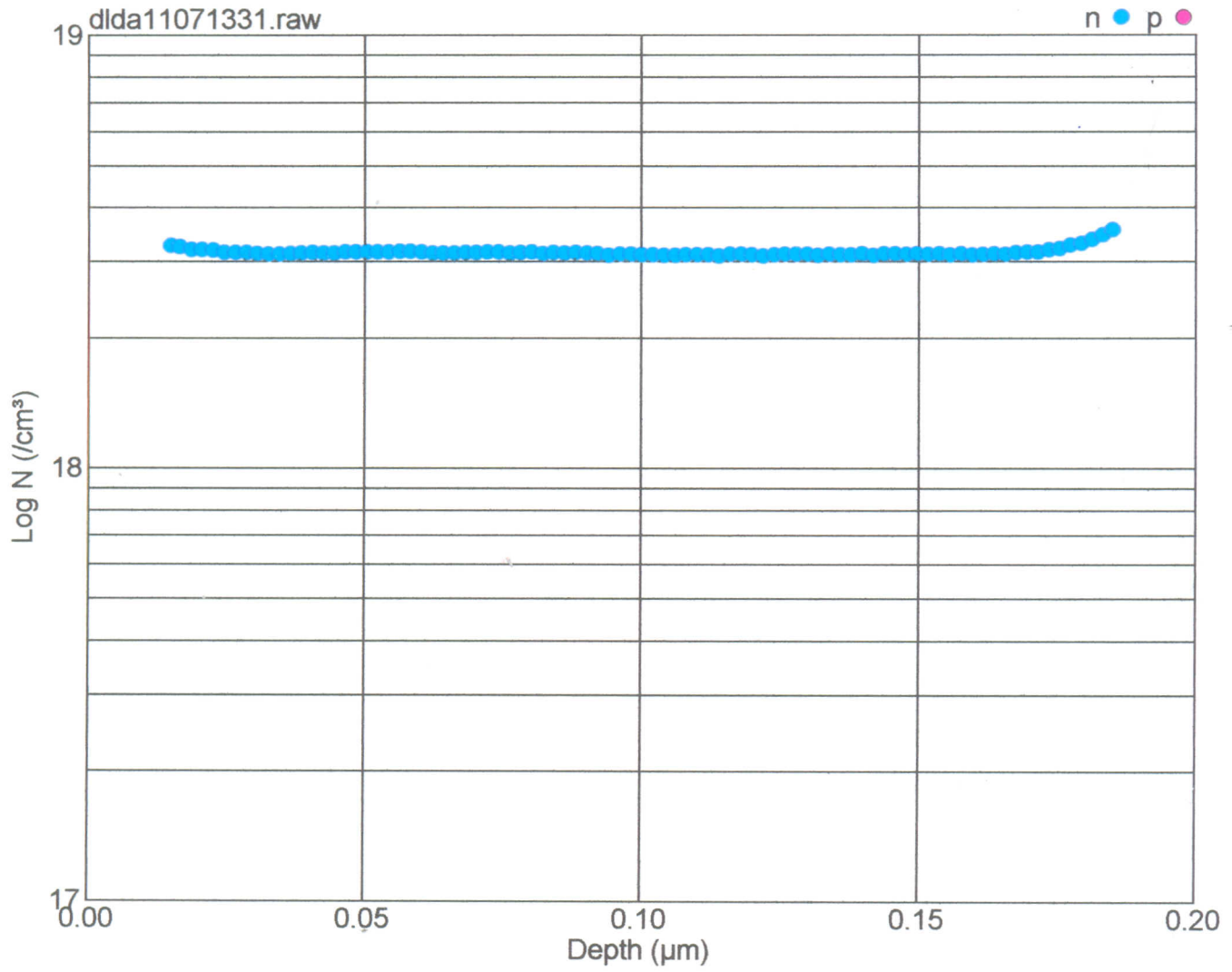
Reg End Mat1 +% Mat2 model EAC freq A-wet A-ill
1 26 InP 0 GaAs Parall Off 0.00 0.0945 0.0960



Reg End Mat1 +% Mat2 model EAC freq A-wet A-ill
1 356 InP 0 GaAs Parall Off 0.00 0.0089 0.0070



Reg End Mat1 +% Mat2 model EAC freq A-wet A-ill
1 87 InAs 47 GaAs Parall Off 0.00 0.0956 0.0940



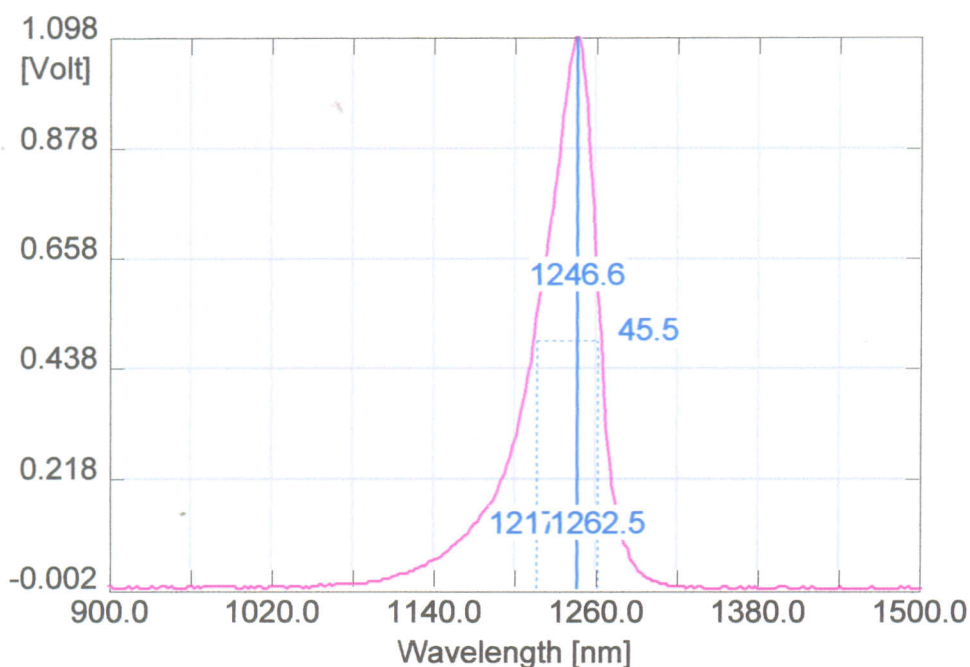
ACCENT RPM2000

Date : July 13, 2011 15:38:55 Operator :
 Wafer ID : q-qw Batch ID : dlda1107133
 Material : InP Thickness : 350 μ m
 Filename : D:\2011\dlda\1107133\q-qw1.spl
 Description :
 Recipe :

Scan parameters
 X : -2.5 mm
 Y : 1.0 mm
 Scan rate : 100 pts/s
 Temperature : 24.2 C

Wavelength settings
 Range : 899.8 to 1532.2 nm
 Slit width : 0.500 mm
 Grating : 150g/mm-1250
 Detector : InGaAs
 Gain : x1 (corr.)
 Filter : 570nm HP
 Calibration : (none)

Laser parameters
 Name : 532nm CW 10mW
 Wavelength : 532.0 nm
 Power : 6.3 mW

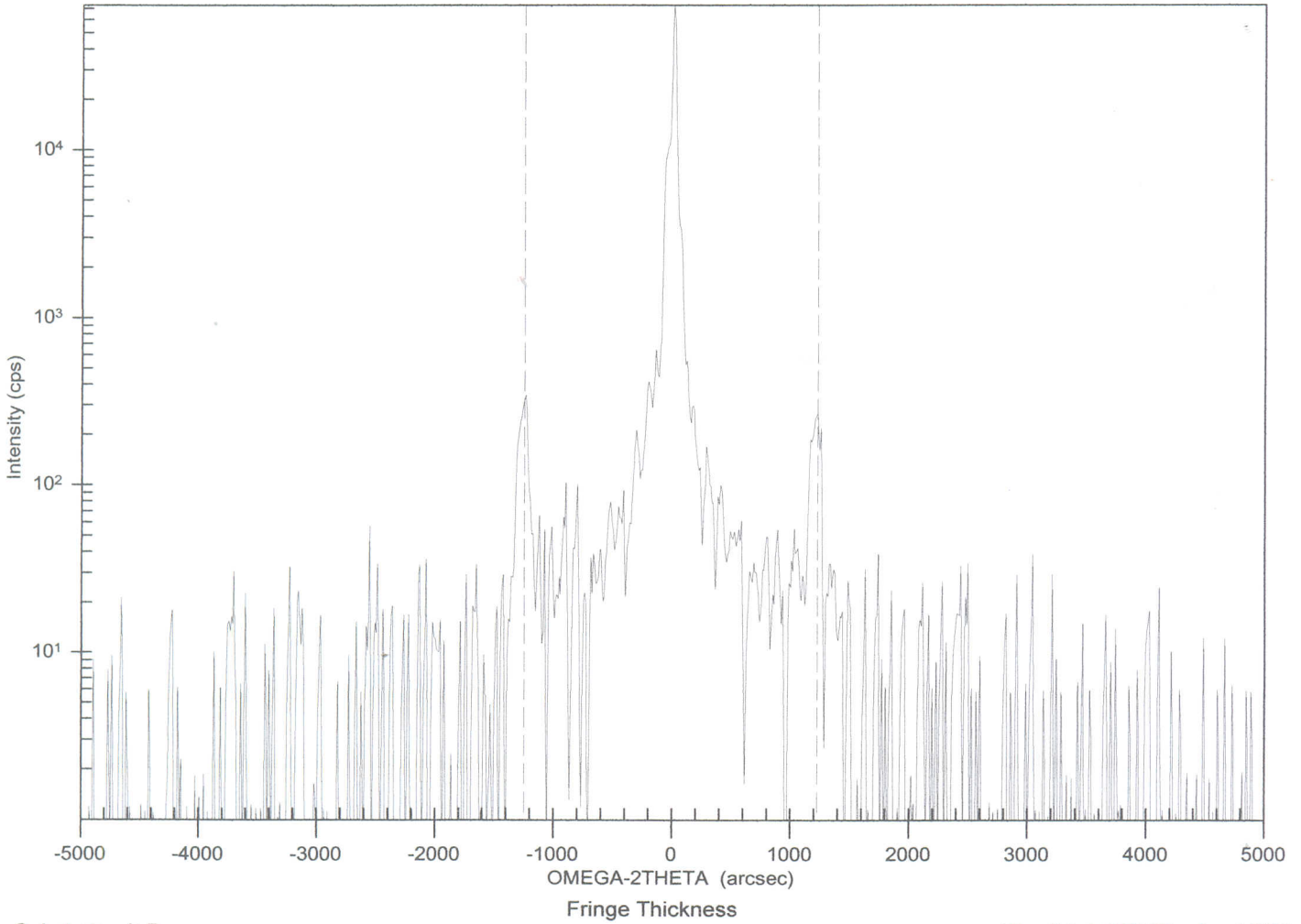


Analysis Parameters
 Mode : Custom 2
 Min Limit : 900.0 nm
 Max Limit : 1500.0 nm
 Threshold : 97.0 %
 FWHM : 50.0 %

Results
 Peak : 1246.6 nm
 Height : 1.098 Volt
 FWHM : 45.5 nm
 Area : 29 a.u.

Fringe Thickness Analysis

dlda1107133c_0aa1.X01



Substrate: InP
Epilayer: -
Average Fringe Spacing: 1236.66 arcsec
Thickness: 150.95 Å

ID: dlda1107133c_0aa1.X01
h,k,l: (0,0,4)
Number of Fringes: 2



10: Martin Yan

規格需求表 (SPECIFICATIONS CONFORMATION) (LM-WORKP-DC-T1)

1. 功能模式來源: 契約 訂單 年度營運計畫書
(Order Type)

2. 功能簡述:
(Function Description) 1250nm LD Epi-wafer

3. 相關法令、規章(附件) (Local Regulations for the Products Specified): 無(Non)

4. 制定者: UCSB
(Specified By)

5. 制定日期: 2011/03/09
(Date of Specification)

6. 規格制定(Specifications):

序號 (No.)	規格需求項目 (Item Name)	規格值 (Value for Customer)	單位 (Unit)	誤差 (DP)	工作條件 (Test Condition)	備註 (Note)
0	N- InP Substrate (M01*)	S-Doped, (>2x10 ¹⁸)	cm ⁻³	---	---	2" wafer, 350±25µm
1	U- InP Buffer Layer	0.2	µm	±10%	---	---
2	P- In _{0.53} Ga _{0.47} As (Concentration)	0.1 (1x10 ¹⁹)	µm (cm ⁻³)	±10% (±20%)	---	---
3	P-InP Layer (Concentration)	1.5 (2→1x10 ¹⁸)	µm (cm ⁻³)	±10% (---)	C-V Test	On test wafer
4	U-In _{0.5339} Al _{0.283} Ga _{0.1831} As (+0.05% CS λ _g =1.1µm) SCH	0.15	µm	±10%	---	---
5	12x U- In _{0.5721} Al _{0.187} Ga _{0.2409} As Well (+0.3% CS, λ _g =1.3µm) / 13x U- In _{0.4688} Al _{0.29} Ga _{0.2412} As Barrier(-0.4% TS, λ _g =1.05µm) (λ _{PL})	9 / 6 (1250)	nm (nm)	±10% (±10nm)	DXRD & PL Measurement	On epi-wafer
6	U- In _{0.5339} Al _{0.283} Ga _{0.1831} As (+0.05% CS λ _g =1.1µm) SCH	0.075	µm	±10%	---	---
7	N-InP Layer (Concentration)	110 (3x10 ¹⁸)	nm (cm ⁻³)	±10% (±20%)	C-V Test	On test wafer
8	2xN-In _{0.85} Ga _{0.15} As _{0.327} P _{0.673} / 2xN-InP (Concentration)	7.5 / 7.5 (3x10 ¹⁸)	nm (cm ⁻³)	±10% (±20%)	---	---
9	N-InP (Concentration)	10 (3x10 ¹⁸)	nm (cm ⁻³)	±10% (±20%)	---	---
10	N- In _{0.53} Ga _{0.47} As (Concentration)	0.2 (3x10 ¹⁸)	µm (cm ⁻³)	±10% (±20%)	---	---
#	Lattice Mismatch	<±1000	ppm	---	DCXD measurement	Test on center of epiwafer

7. 研發部主管: Brian Chan
(R&D Manager)

8. 技術部主管: Wei Lin
(Supervisor)

9. 需求者/客戶簽認: Yongho Zeng
(Customer Confirmation) (signature)

公司名稱: UCSB.
(Customer)

10. 管制碼: 規需 0707231-2 (Control No.)
(Please mail back after the confirmation signature by manager who make this order)

保存年限: 叁年

密等: 密

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